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(12) **United States Design Patent**
Kaneko et al.

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(54) **INNER TUBE FOR PROCESS TUBE FOR MANUFACTURING SEMICONDUCTOR WAFERS**

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(*) Notice: This patent is subject to a terminal disclaimer.

(**) Term: **14 Years**

(21) Appl. No.: **29/420,539**

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(30) **Foreign Application Priority Data**

Nov. 18, 2011 (JP) 2011-026687

(51) **LOC (10) Cl.** **13-03**

(52) **U.S. Cl.**
USPC **D13/182**

(58) **Field of Classification Search**
USPC D13/182; D23/266; D7/600.1, 600.2; 118/715, 722, 724, 725; 219/385, 390, 219/486, 520, 523; 83/35, 39; 138/118, 138/118.1, 121, 177, 178; 206/454, 711; 211/41.18; 414/935; 432/247, 253
See application file for complete search history.

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(57) **CLAIM**

The ornamental design for an inner tube for process tube for manufacturing semiconductor wafers, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of an inner tube for process tube for manufacturing semiconductor wafers showing our new design;

FIG. 2 is a front view thereof;

FIG. 3 is a rear view thereof;

FIG. 4 is a right side thereof;

FIG. 5 is a left side view thereof;

FIG. 6 is a top plan view thereof;

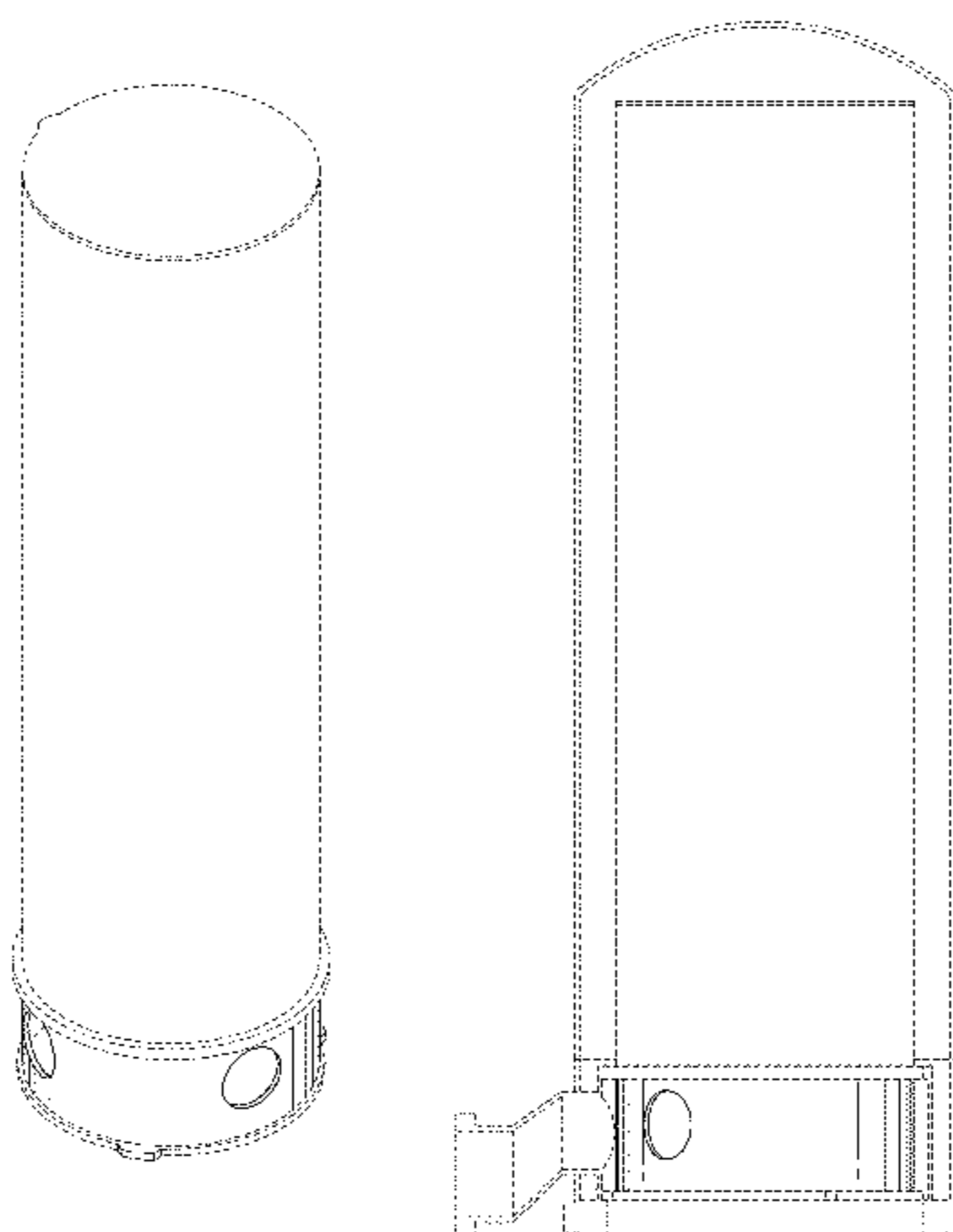
FIG. 7 is a bottom plan view thereof;

FIG. 8 is an enlarged cross-sectional view taken along line 8-8 of FIG. 2; and,

FIG. 9 is another front view thereof, shown in a used condition.

The broken lines shown in the drawings represent portions of the inner tube for process tube for manufacturing semiconductor wafers that form no part of the claimed design.

1 Claim, 8 Drawing Sheets



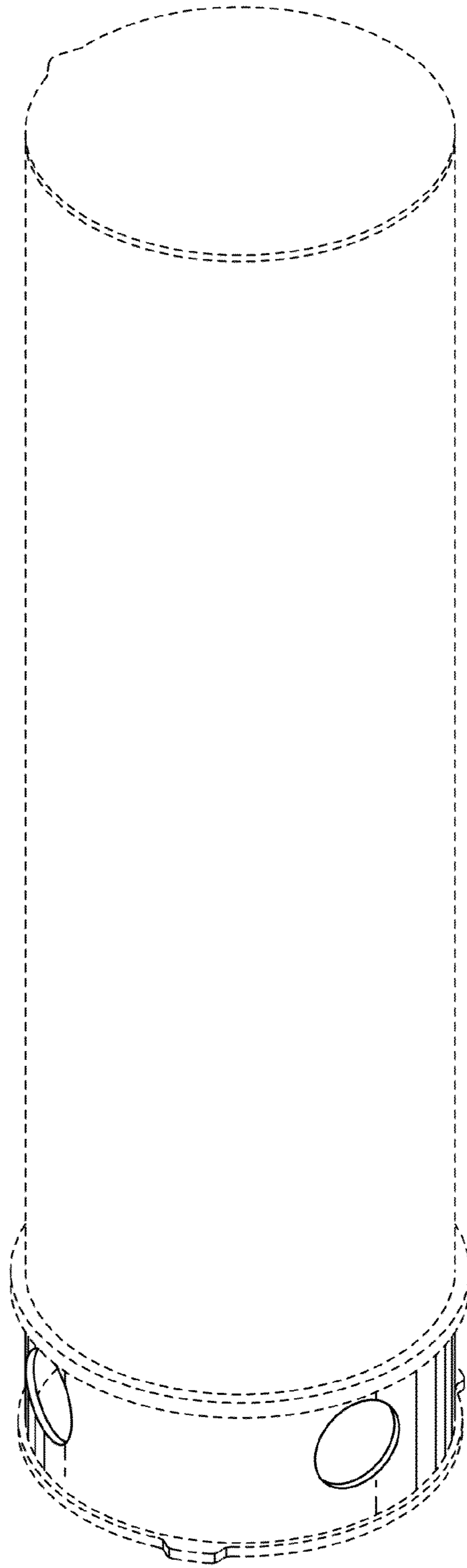


FIG. 1

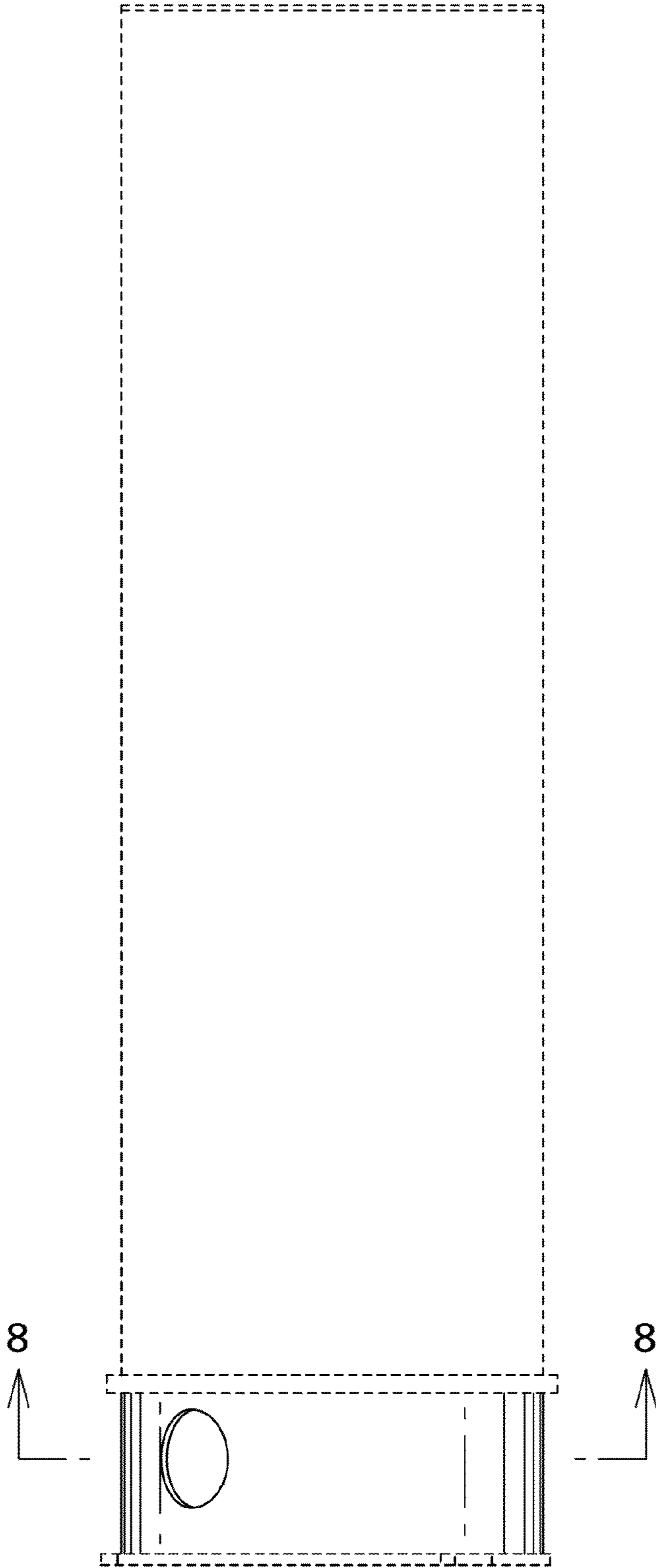


FIG. 2

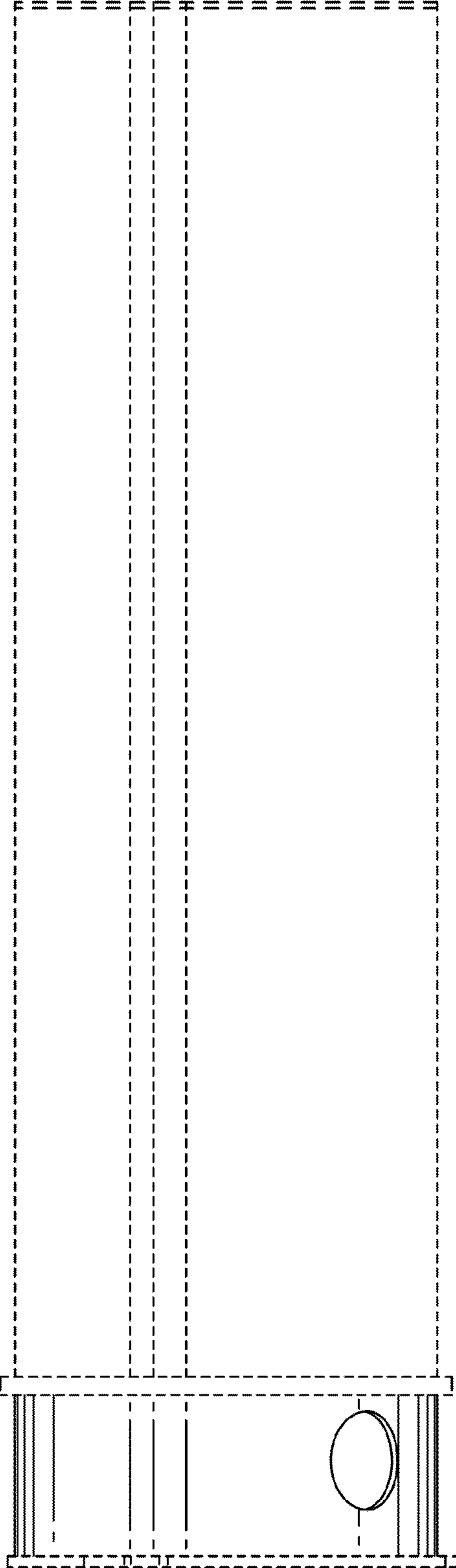


FIG. 3

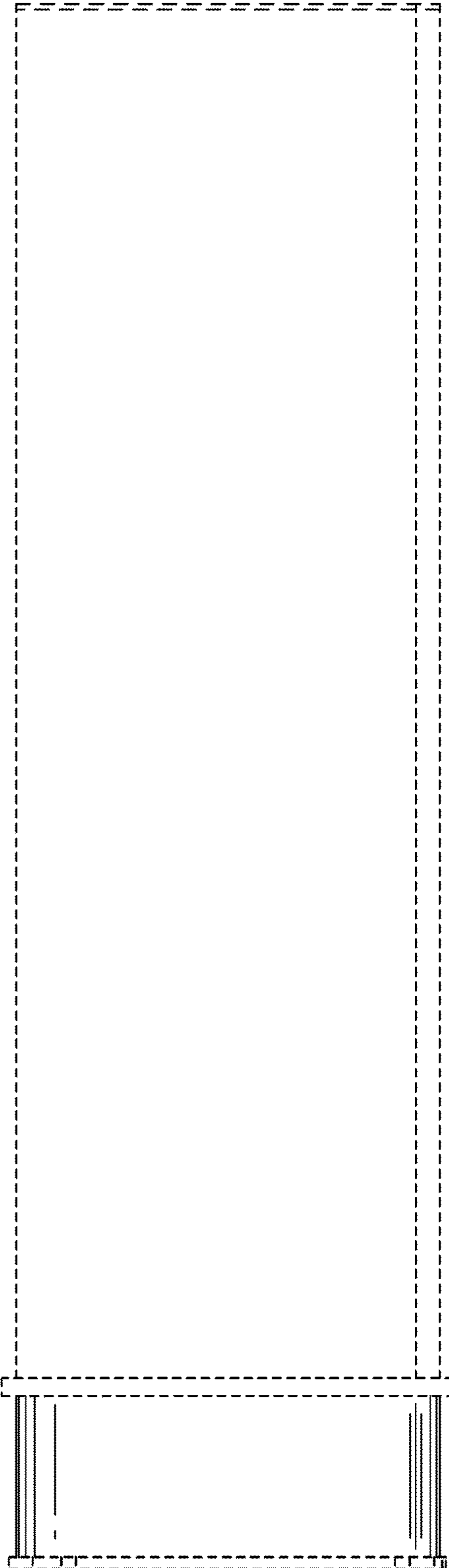


FIG. 4

Application No. 29/420,539
Amendment dated October 6, 2014
Reply to Office Action of July 15, 2014
Replacement Sheet

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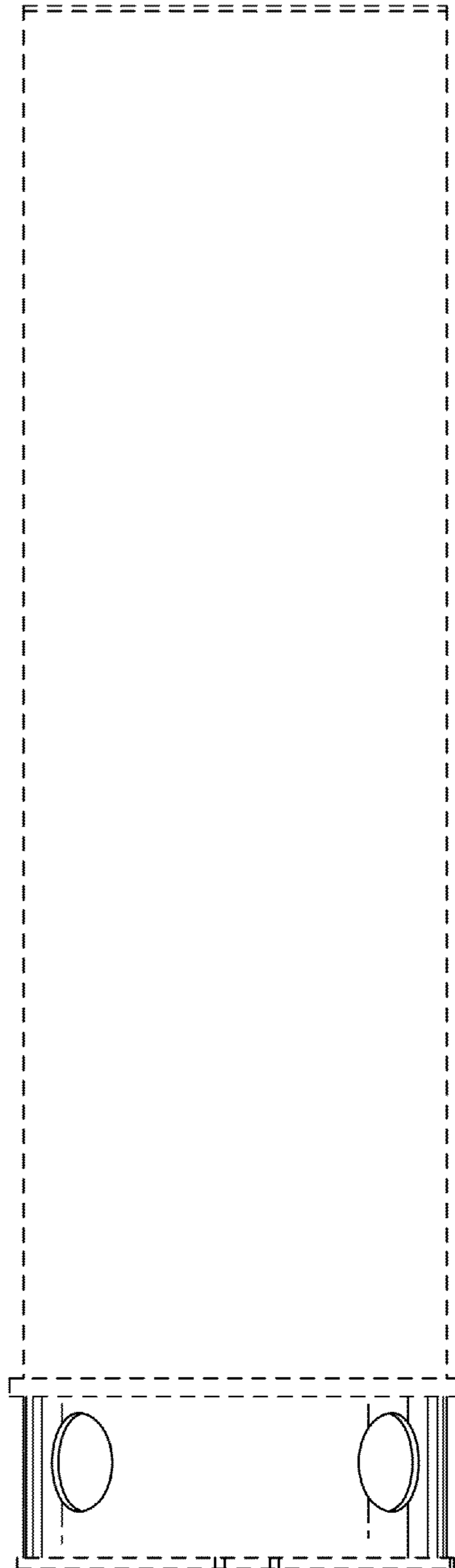


FIG. 5

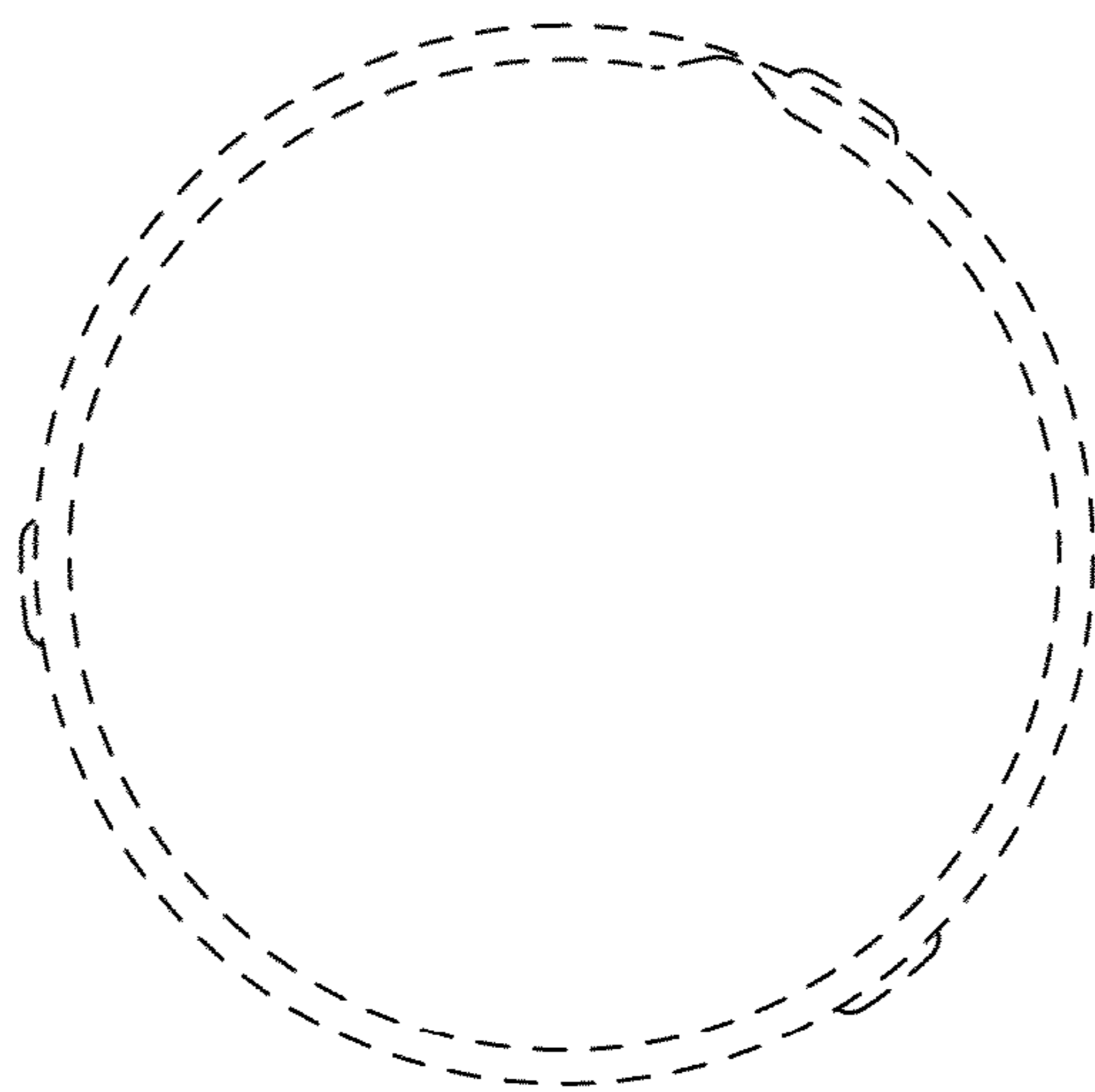


FIG. 6

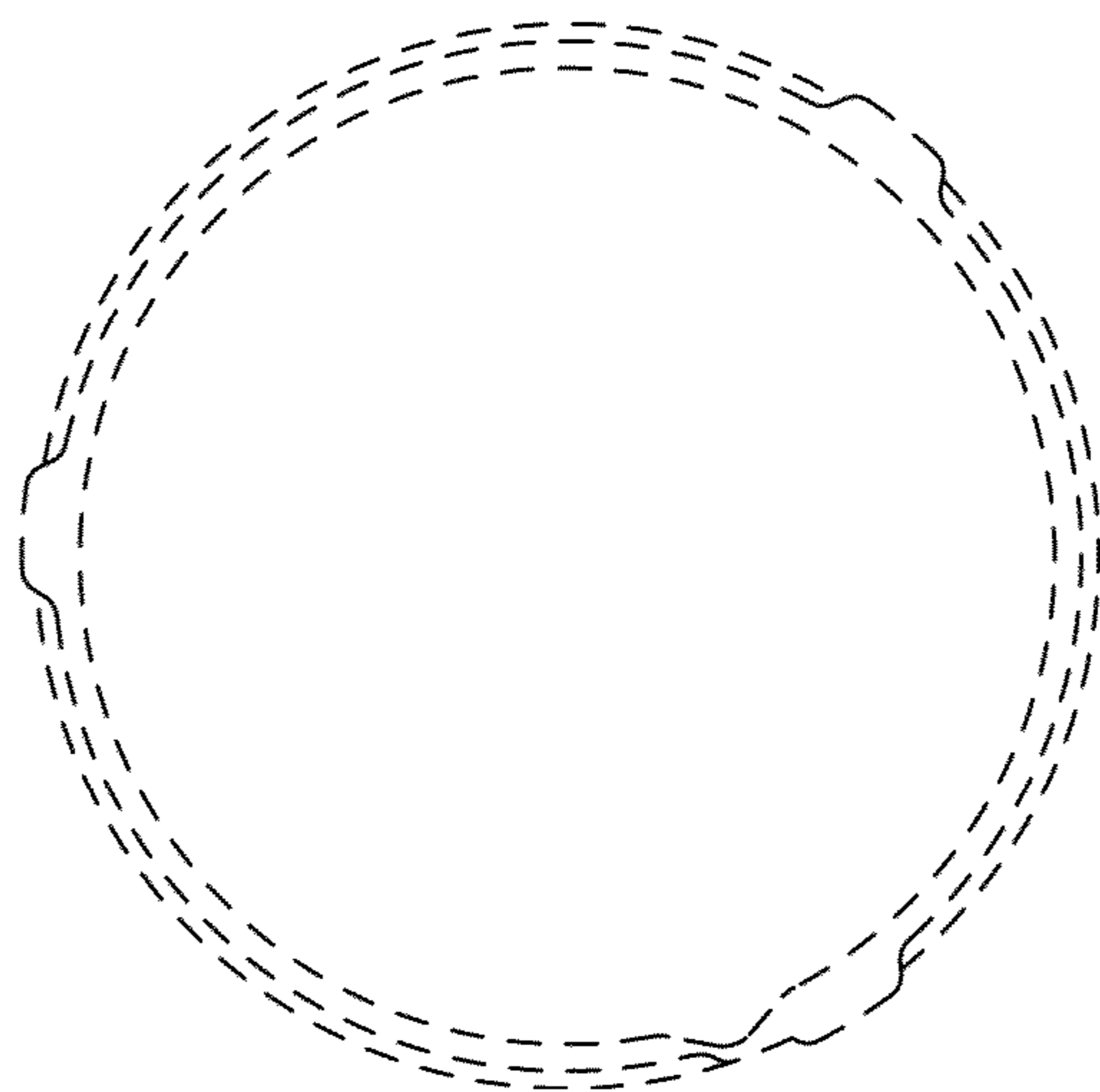


FIG. 7

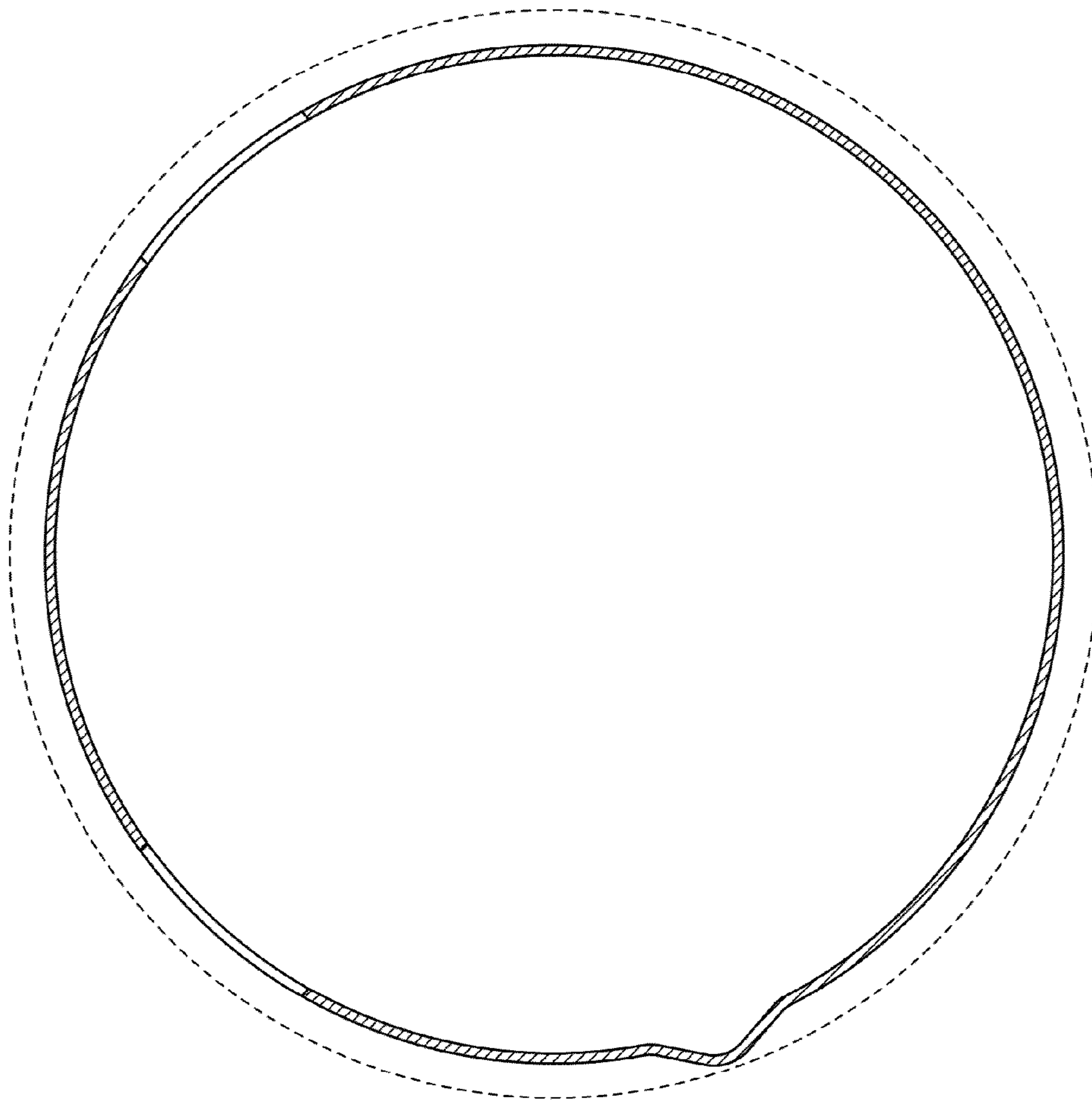


FIG. 8

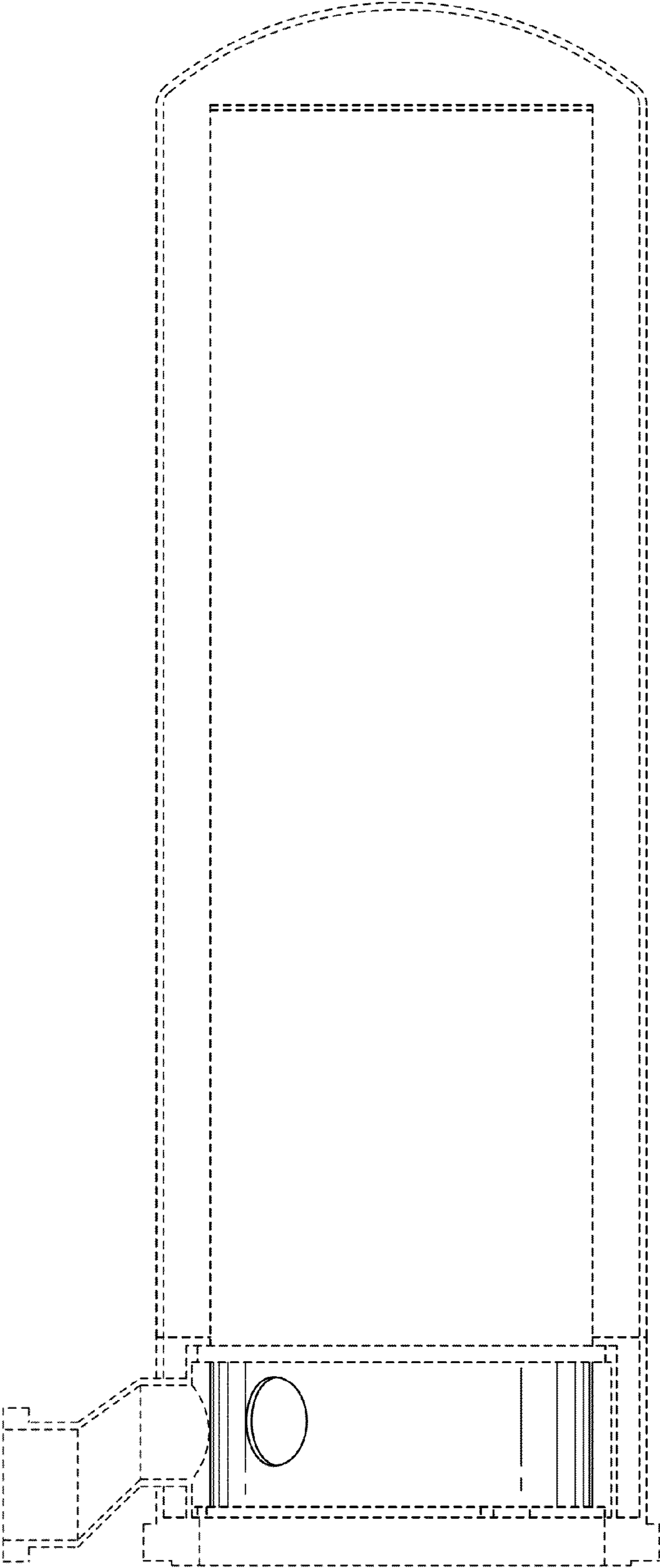


FIG. 9